

# Development of a novel 2D position-sensitive semiconductor detector concept



Daniela Bassignana, Manuel Lozano,  
Giulio Pellegrini, David Quirion



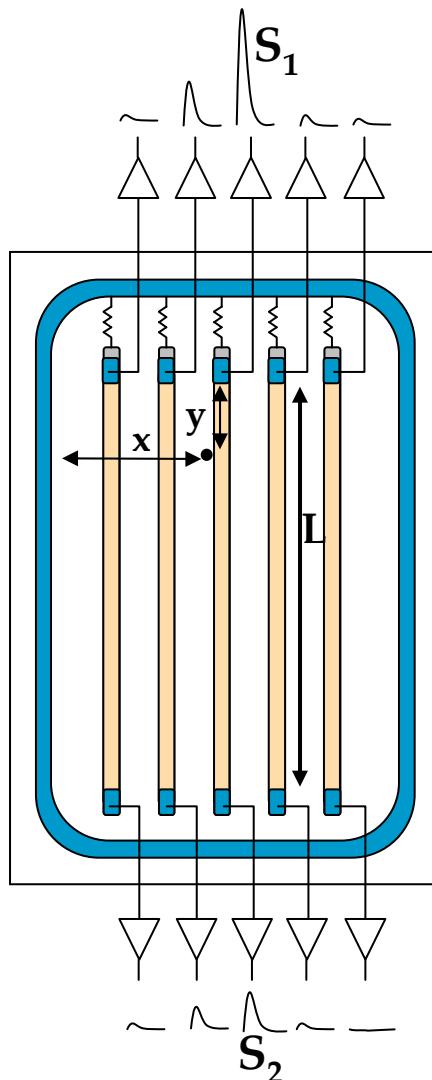
Iván Vila, Marcos Fernández, Francisca  
J. Muñoz, Richard Jaramillo



- New detectors concept
- Simulation Models and results
  - First prototypes
  - Second prototypes
  - Conclusions

# New detectors concept

Simple single-sided AC-coupled microstrip detectors with resistive coupling electrodes.



- X-coordinate: charge sharing between neighbouring strips\*.
- Y-coordinate: Resistive charge division method.

- ✓ Electrode resistance >> preamplifier impedance.
- ✓ Optimal shaping time (to reduce the ballistic deficit effect).

$$\begin{aligned} S_1 &= f(y) \\ S_2 &= f(L-y) \end{aligned}$$

$$\frac{y}{L} = \frac{S_2}{S_1 + S_2}$$

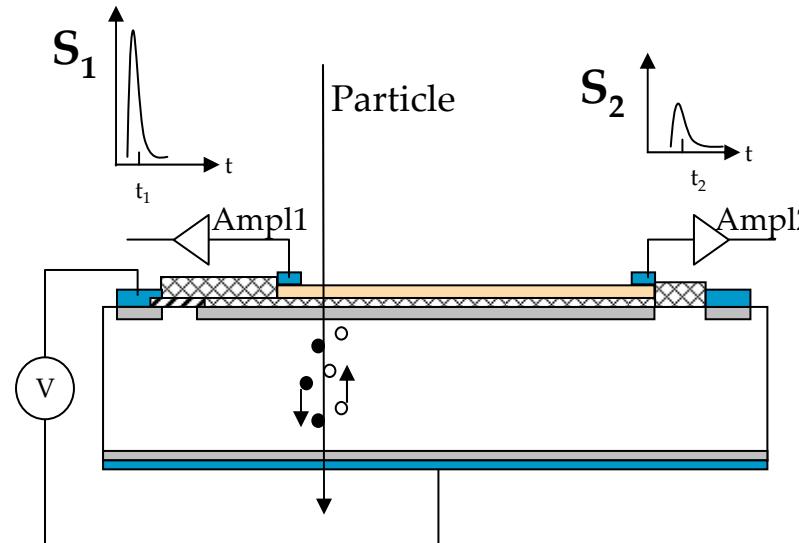
Resistive electrodes uncoupled from the diode structures of the detector.

\*\* V. Radeka, IEEE Transaction on Nuclear Science NS-21 (1974) 51

# Resistive charge division in microstrip detectors

Resistive electrodes represent diffusive RC lines.

- Signal amplitude attenuation during propagation towards the preamplifier.
  - $R_{\text{electrode}}$  fixed: longer propagation  $\rightarrow$  smaller signal amplitude.
  - Electrodes length fixed: higher  $R_{\text{electrode}}$   $\rightarrow$  smaller signal amplitude.
- Rise time of the propagating signal increases the further the pulse travels.
  - Non constant ballistic deficit effects (propagation length,  $R_{\text{electrode}}$ , shaping time).



We investigated the feasibility of this method by means of simulations and characterization of real proof-of-concept prototypes.

# Simulation Models

## Framework: Virtuoso Spectre by Cadence.

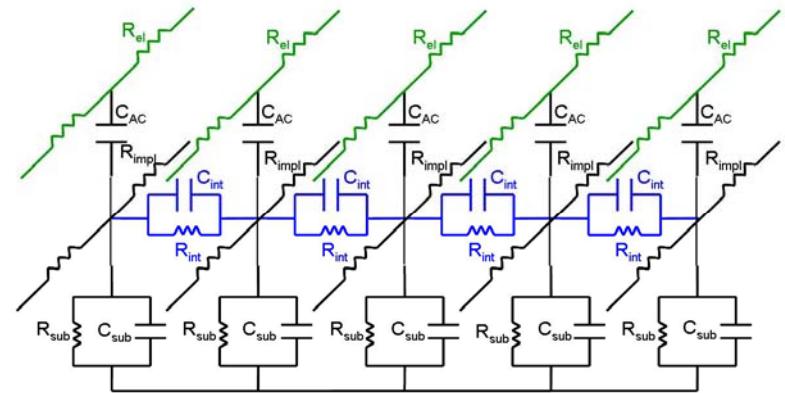
### (2009) Detector ( $p^+$ -on-n) \*\*\*

\*\*\*N. Bacchetta et al., IEEE Transaction on Nuclear Science, VOL. 43, NO. 3, JUNE 1996.

56 (or 80) cells 250  $\mu\text{m}$  long

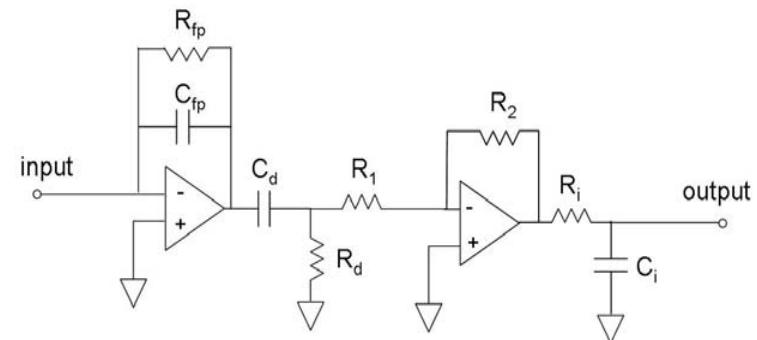
- five strips 14 (or 20) mm long ( $R_{\text{impl}}$ ,  $C_{\text{AC}}$ ,  $R_{\text{el}}$ ),
- $C_{\text{int}}$ ,  $R_{\text{int}}$ ,
- bulk (300  $\mu\text{m}$  thick) representation ( $R_{\text{sub}}$ ,  $C_{\text{sub}}$ ).

The parameters values, as well as the number of cells, have been adapted to the results of the electrical characterization of the real prototypes.



### (2011) Readout electronics

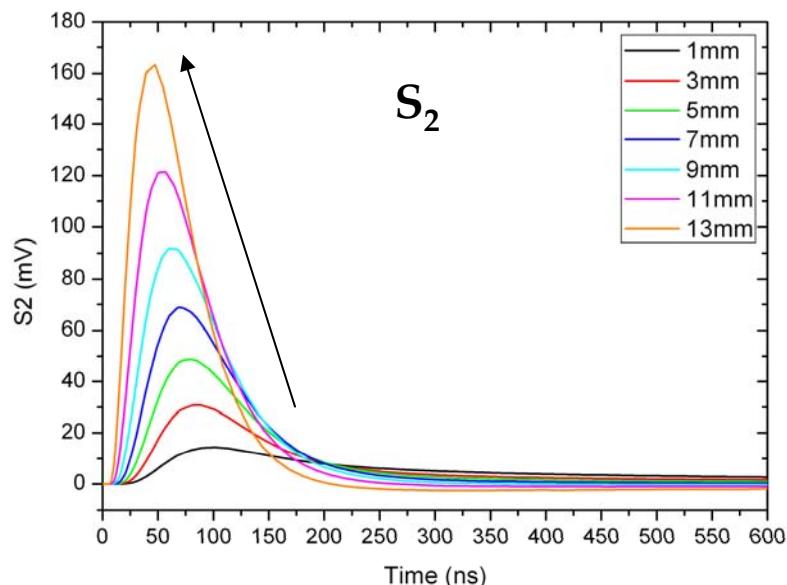
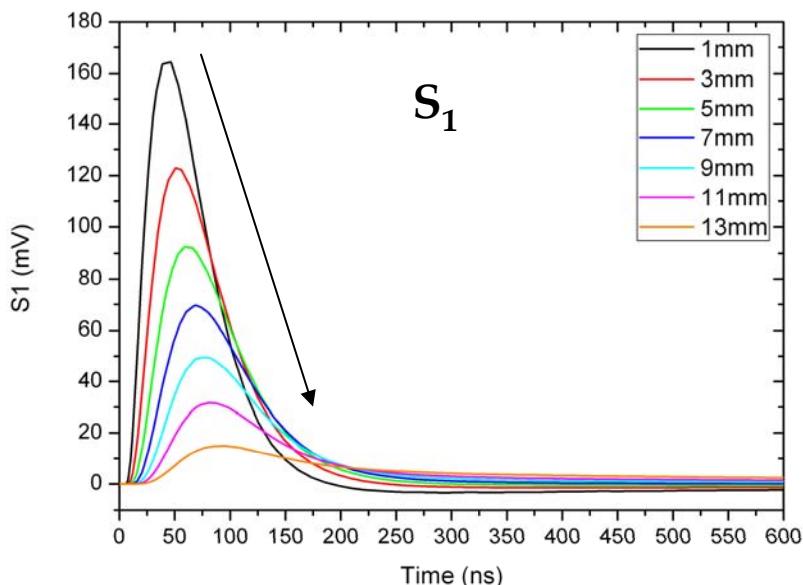
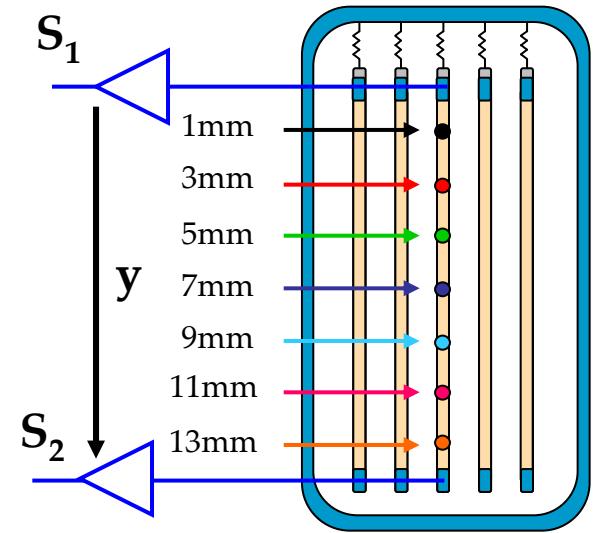
- ideal charge sensitive preamplifiers,
- 1<sup>o</sup>order CR-RC band-pass filter,
- Peaking time 25ns (Beetle chip- ALIBAVA DAQ system).



# First prototypes: Simulation results

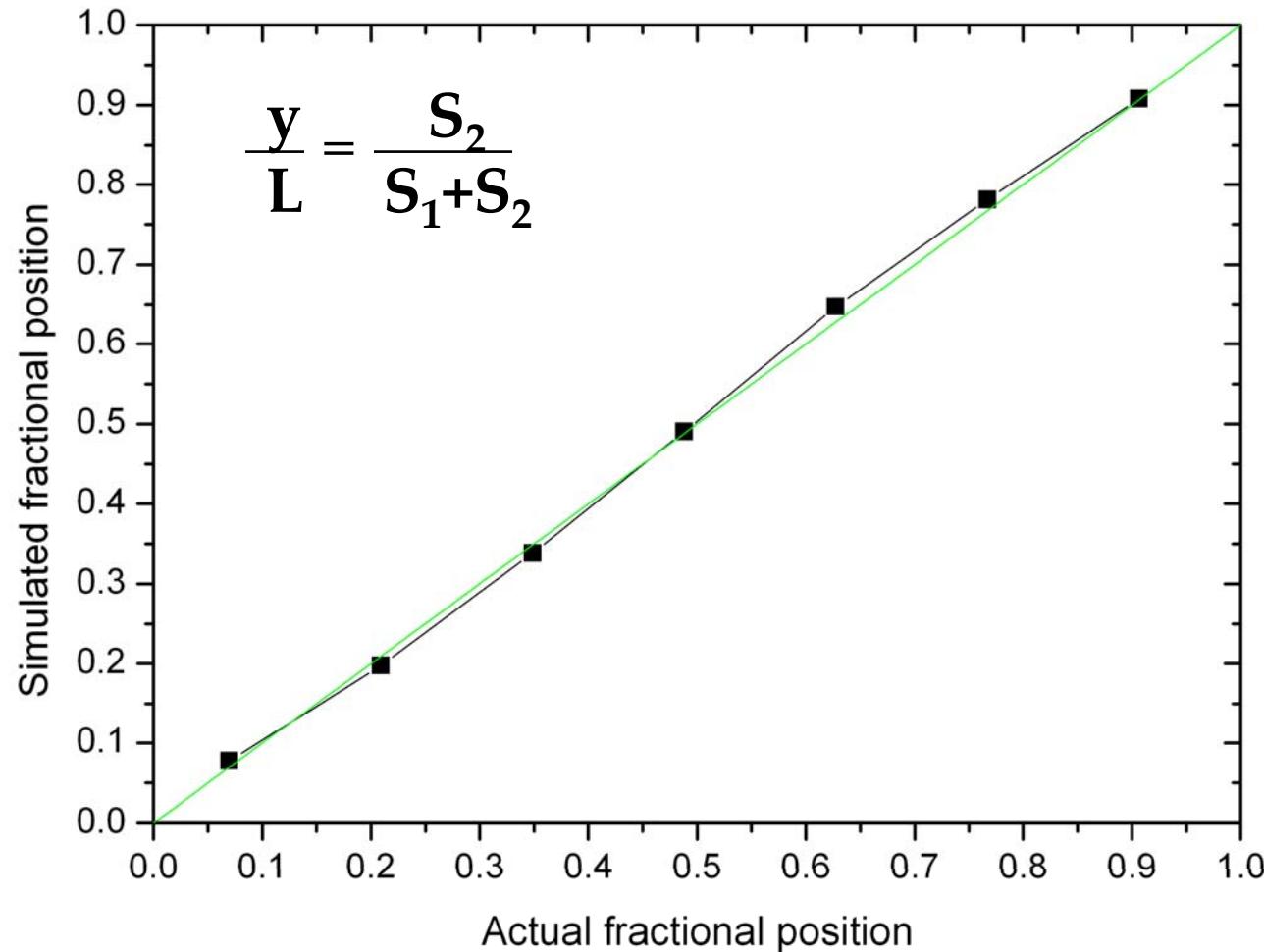
- Strips length 14mm (width 20  $\mu\text{m}$ )
- Electrode resistance  $R_{\text{electrode}}/\mu\text{m} = 20 \Omega/\mu\text{m}$

Current pulse injected by a pulse generator:  
shape and integrated charge equivalent to a  
MIP in 300  $\mu\text{m}$  thick bulk ( $\approx 3.5 \text{ fC}$ ).

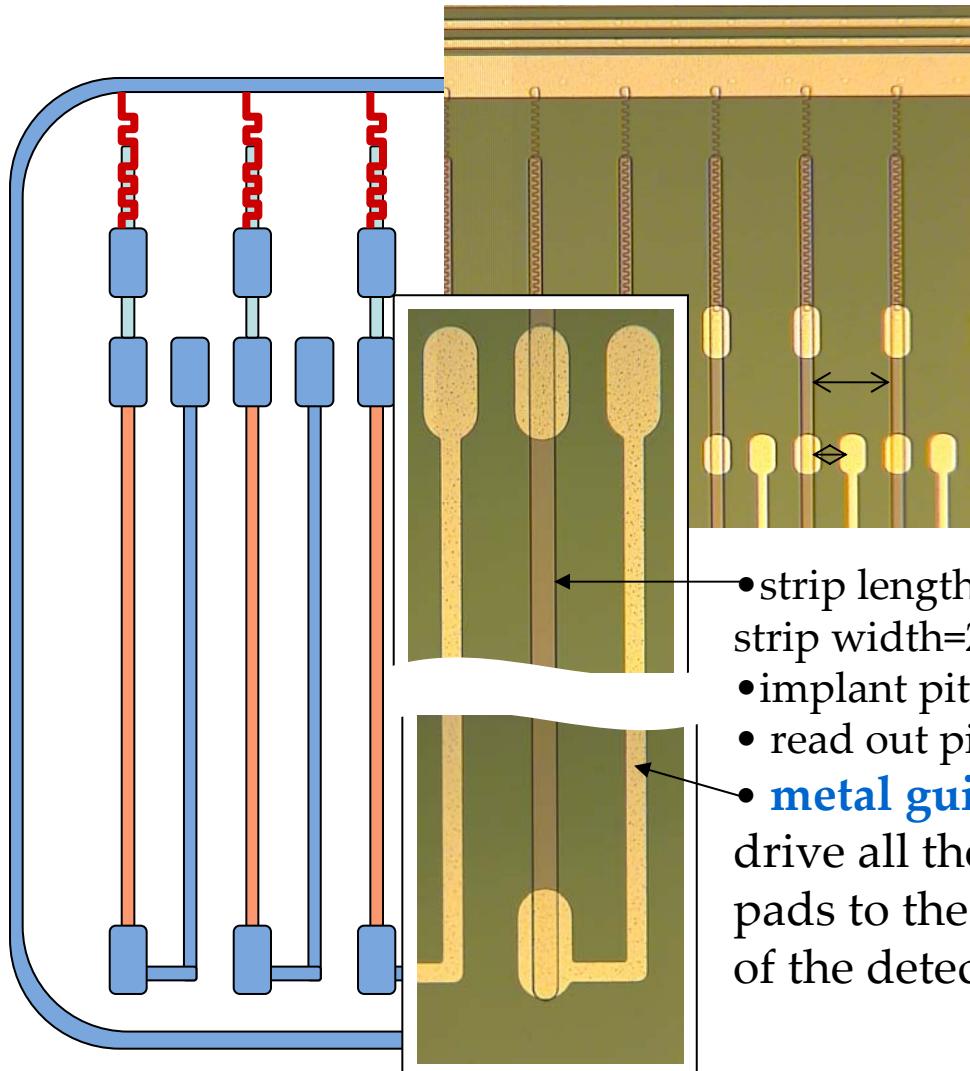


# First prototypes: Simulation results (2)

Simulated fractional position ( $S_2/S_1+S_2$ ) vs the actual one ( $y/L$ )  
Ballistic deficit effects due to a non optimal shaping time.



IMB-CNM facilities of  
Barcelona (2009-2010).



Fabrication run:  
standard technology  
for single-sided p<sup>+</sup>-on-n  
silicon microstrip  
detectors.

Resistive material =  
highly doped  
polysilicon.

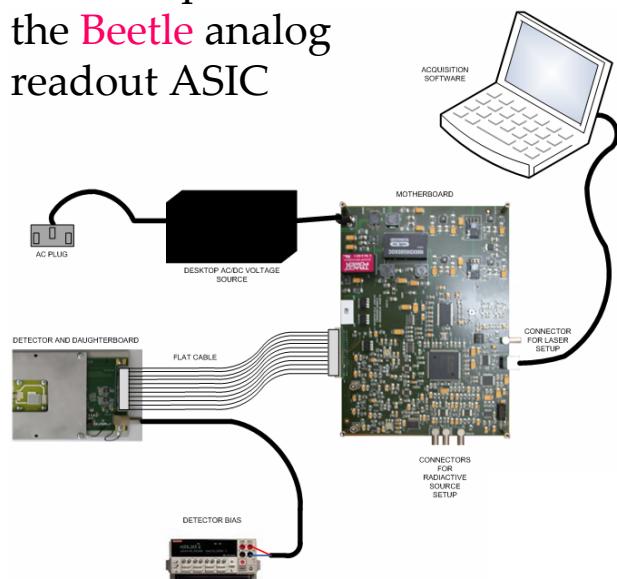
$$R_{\text{electrode}}/\mu\text{m} = 20 \Omega/\mu\text{m}$$

Only one chip  
to read out the  
detector.

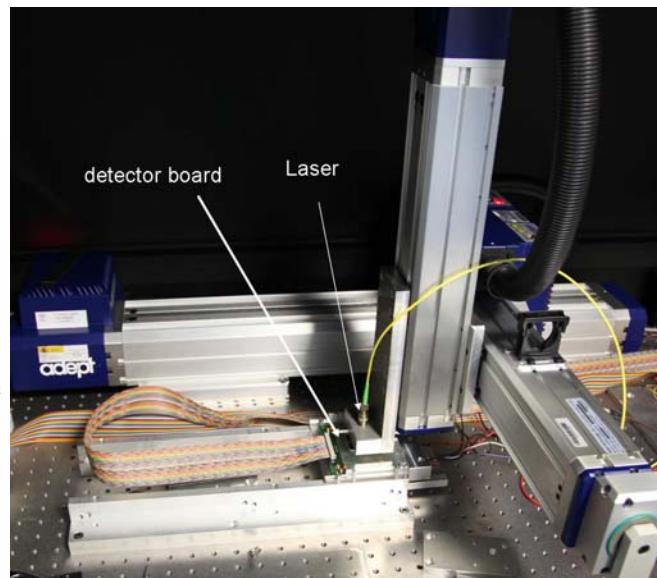
# Experimental arrangement

Detectors have been characterized in the IFCA clean room in Santander

**ALIBAVA DAQ system** for microstrip detectors, based on the **Beetle** analog readout ASIC

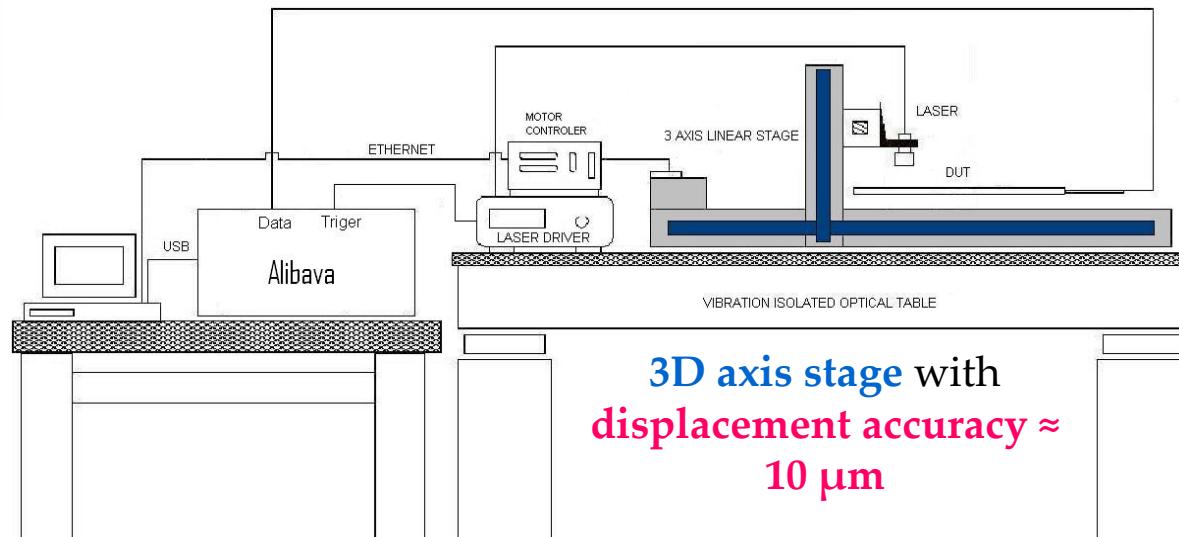


- 256 channels
- **peaking time = 25ns**
- $S/N \approx 20$  for standard no irradiated detectors



**Pulsed DFB laser**

- $\lambda = 1060\text{nm}$
- gaussian beam spot width  $\approx 15 \mu\text{m}$
  - rise time 2ns
  - amplitude 1mV
  - **total charge  $\approx 10\text{MIPs}$**



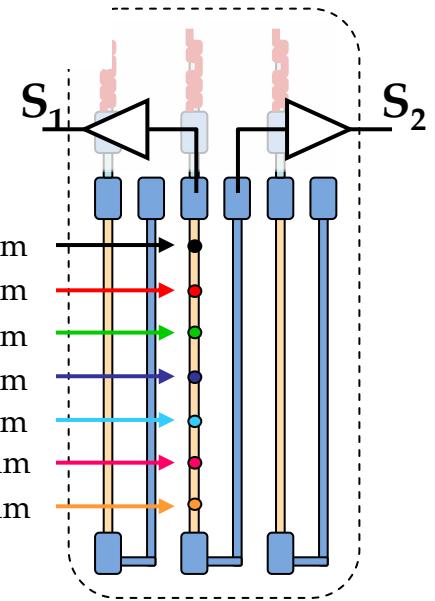
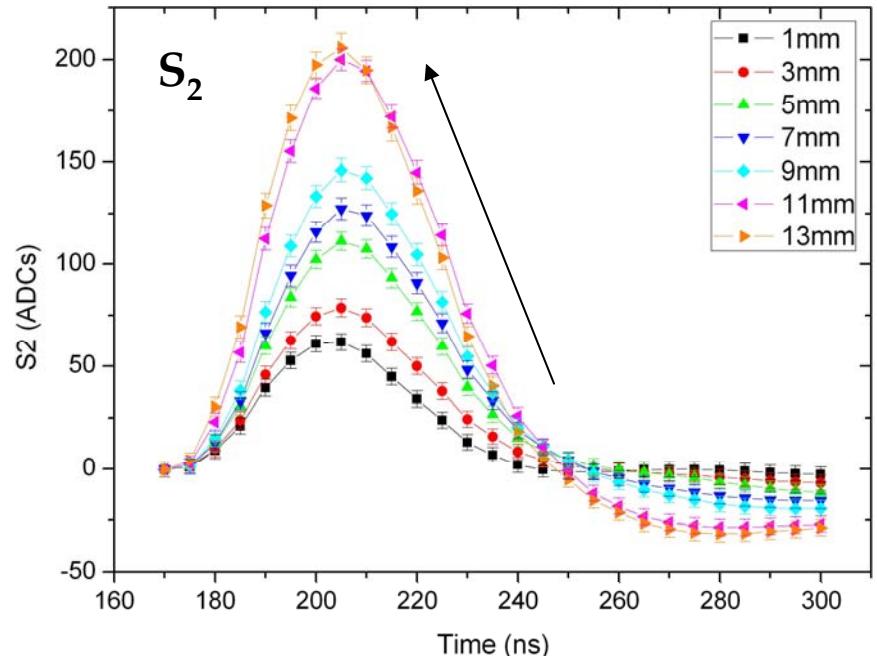
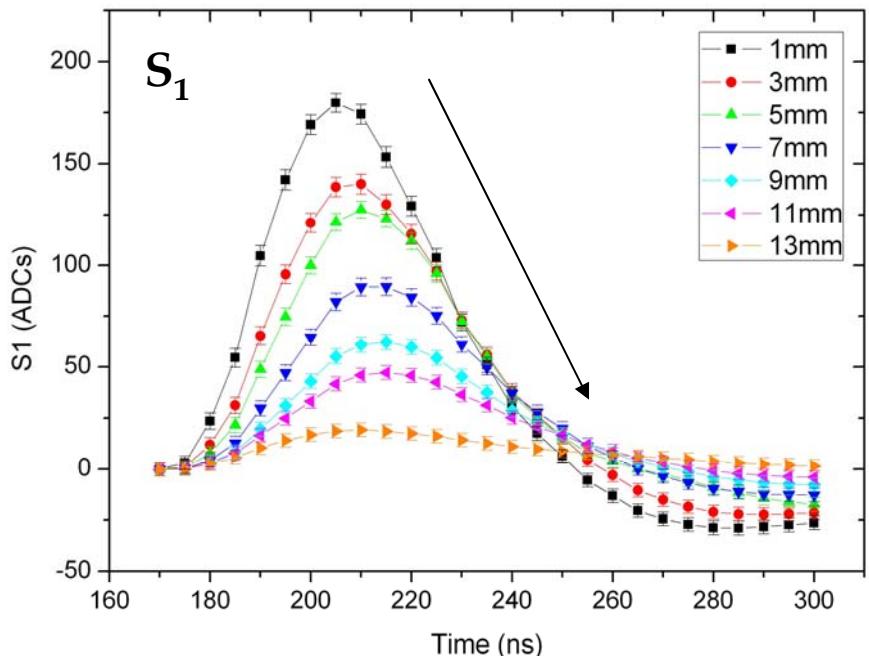
(2010)

# First prototypes: experimental results

Asymmetry in the detector response:

Metal guides capacitively coupled with the neighbouring strips.

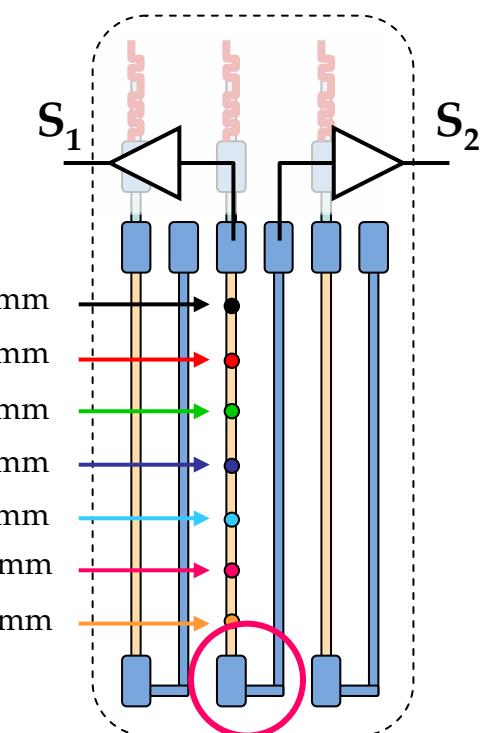
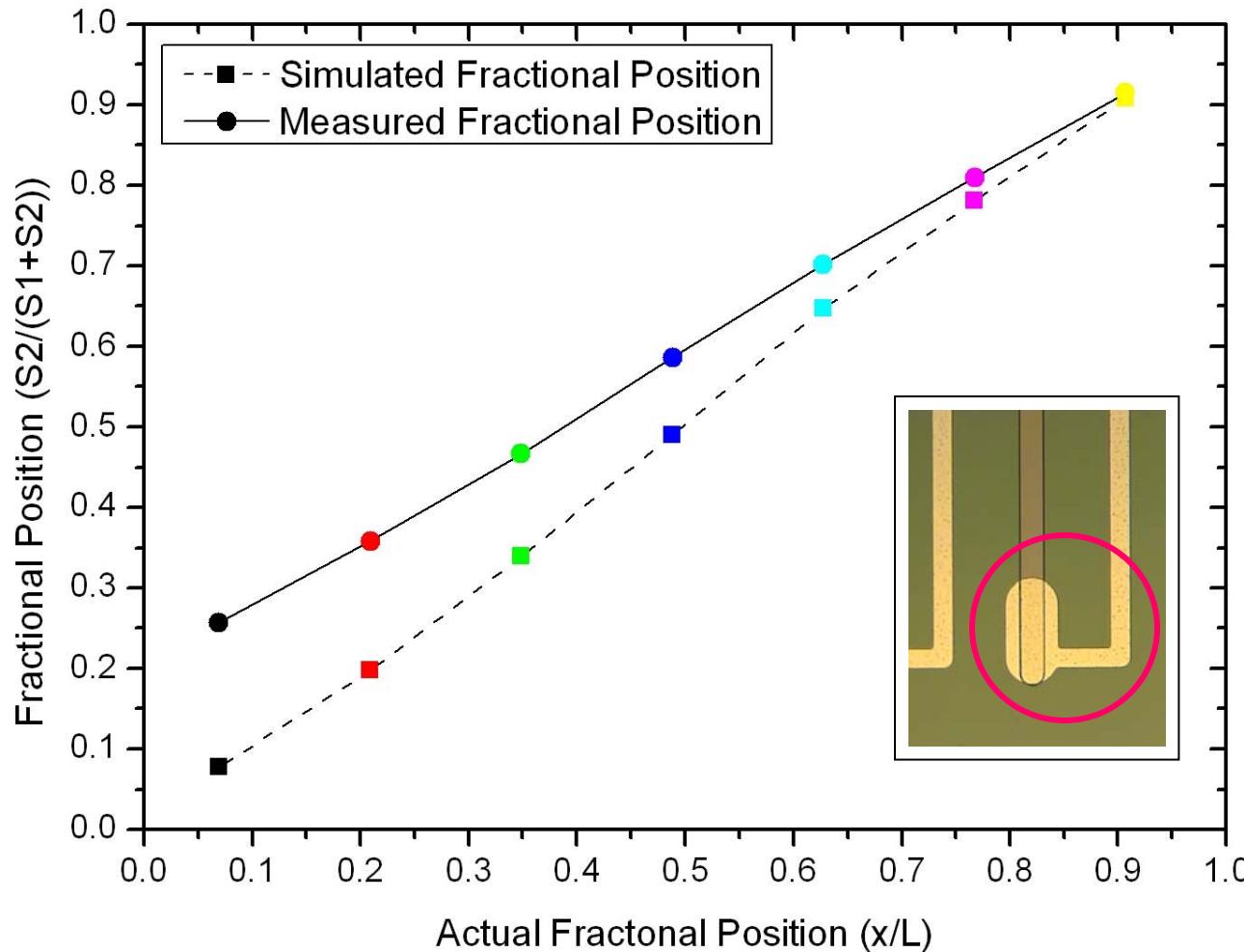
Induced signal components contribute to signal  $S_2$  changing its shape (amplitude and peaking time).



# Experimental results (2)

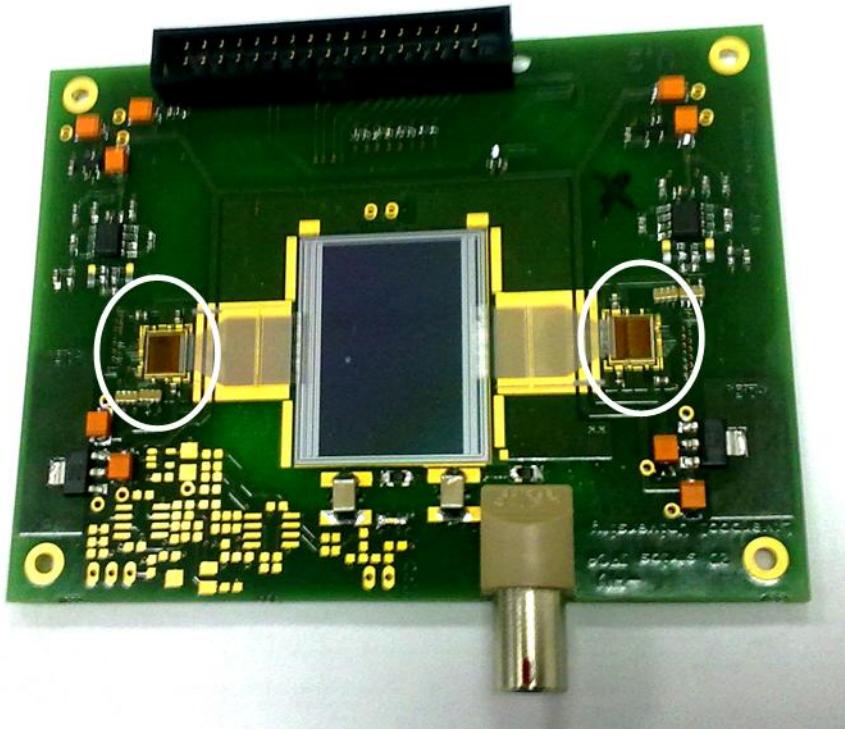
Experimental fractional position ( $S_2/(S_1+S_2)$ ) versus the simulation.

Contribution of induced signal decreases when the laser is placed close to the connection between the resistive electrode and the metal line.



# Second prototypes

Produced at the IMB-CNM facilities of Barcelona (2010).



No metal guides

- strip length= 20 mm,  
strip width=20  $\mu\text{m}$
- Electrode width= 30 $\mu\text{m}$
- pitch= 80  $\mu\text{m}$

Fabrication run:  
standard technology for single-sided p<sup>+</sup>-in-n silicon microstrip detectors.

Resistive material = highly doped poly silicon.

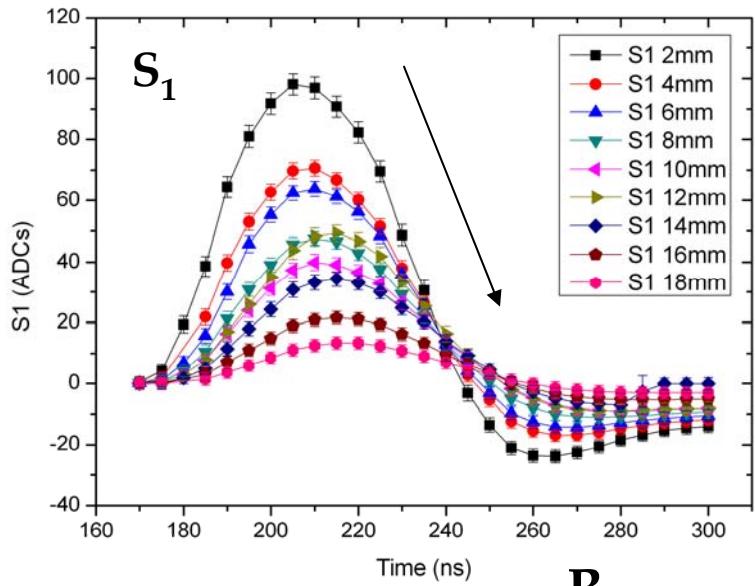
Different concentration of Boron  
→ different values of the electrodes resistance.

$$R_{\text{electrode}}/\mu\text{m} = 2.8 \Omega/\mu\text{m} \text{ or } 12.2 \Omega/\mu\text{m}$$

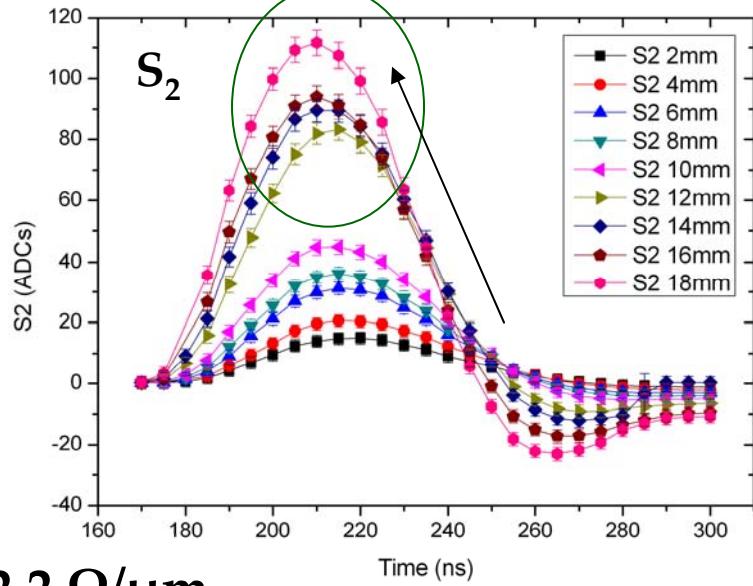
Two chips to read out the detector.

Thanks to Marko Dragicevic (HEPHY institute, Vienna) for his contribution to the mask design and to Gianluigi Casse (University of Liverpool) for the wire bonding.

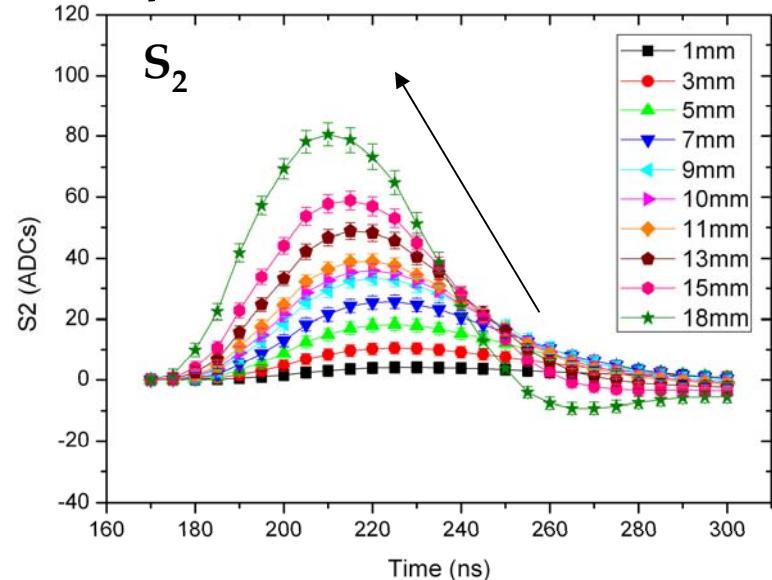
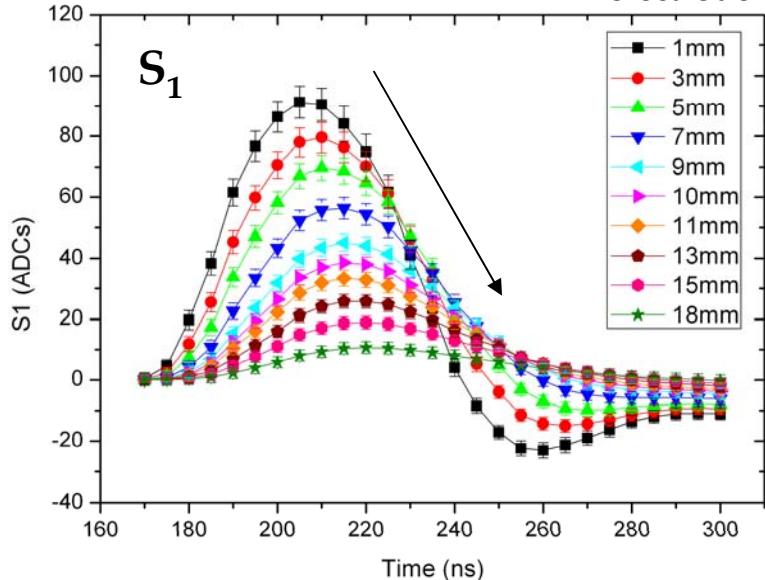
$R_{\text{electrode}}/\mu\text{m} = 2.8 \Omega/\mu\text{m}$



Laser misalignment



$R_{\text{electrode}}/\mu\text{m} = 12.2 \Omega/\mu\text{m}$



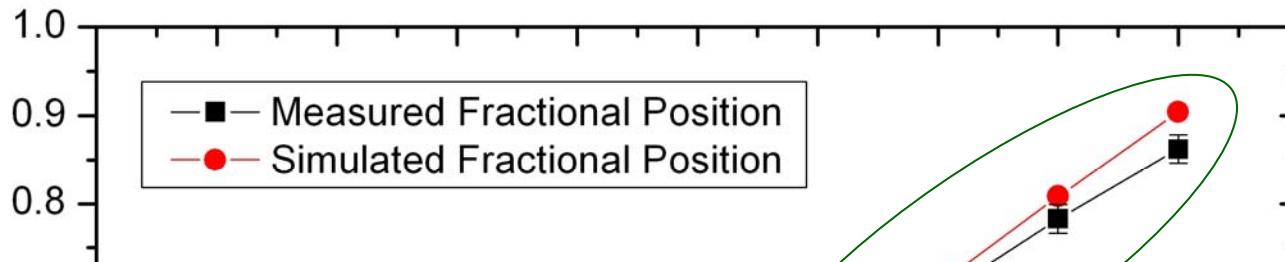
$R_{\text{electrode}}/\mu\text{m} = 2.8 \Omega/\mu\text{m}$

$RC \approx 100\text{ns}$

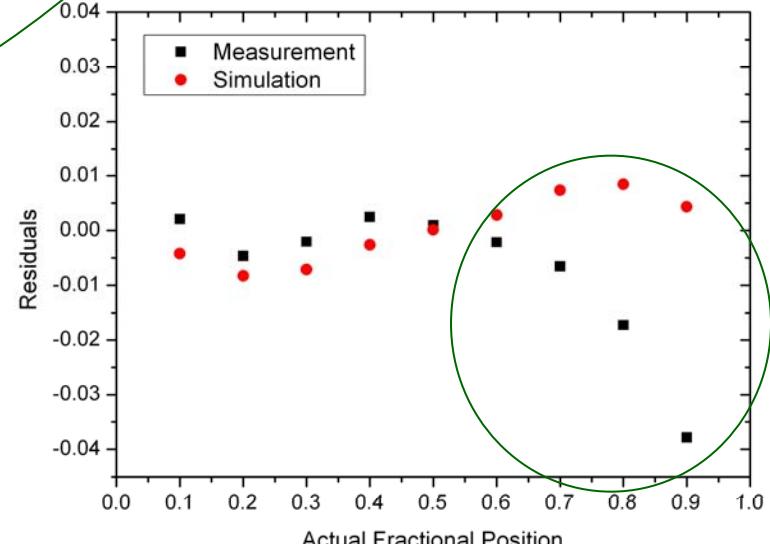
total charge collected  $\approx 35\text{fC}$

Calculated fractional position resolution  $\approx 2\%$

400  $\mu\text{m}$  over 20 mm



$$\frac{y}{L} = \frac{S_2}{S_1+S_2}$$



Actual Fractional Position

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# Fractional Position (2)

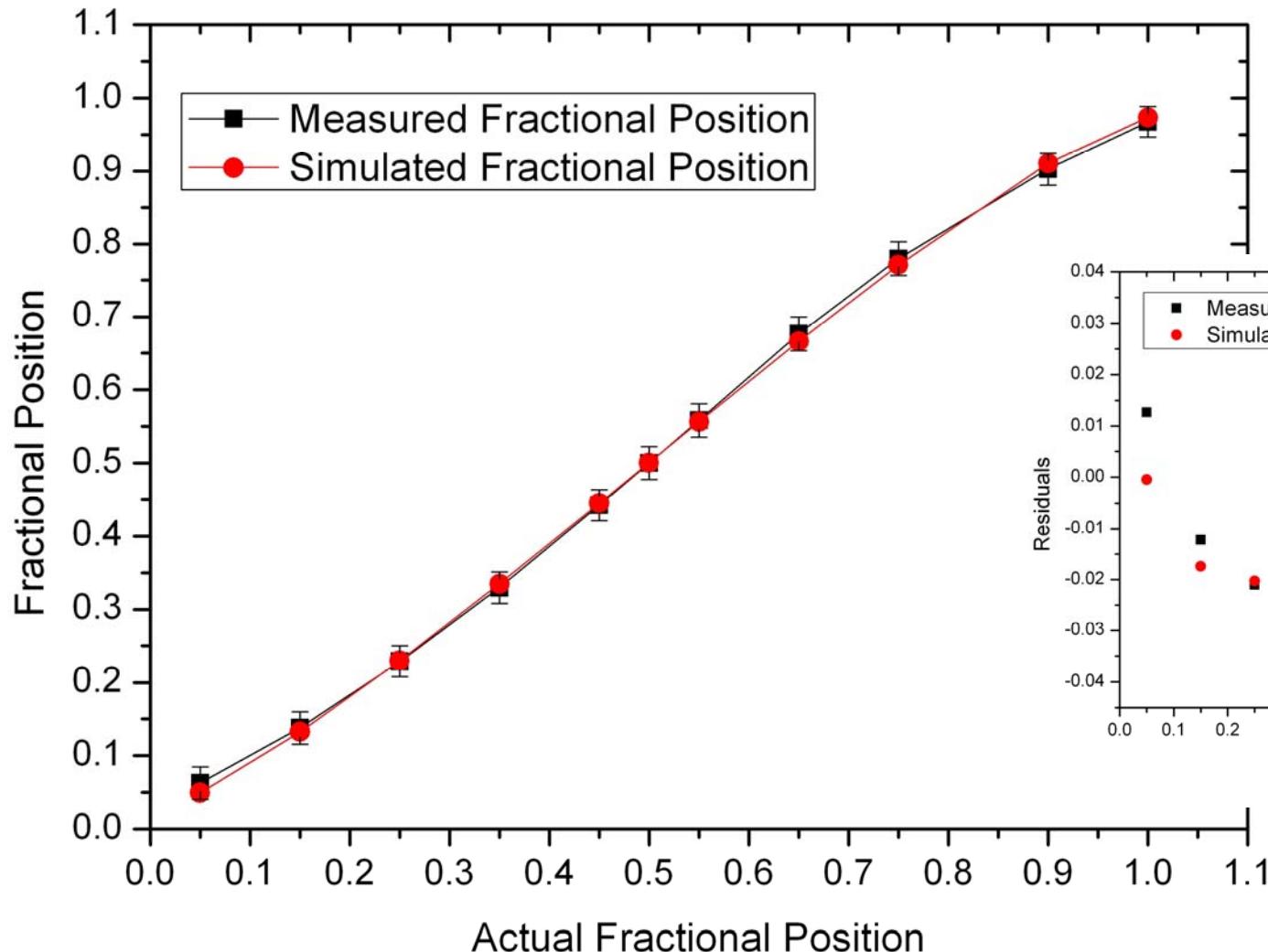
$R_{\text{electrode}}/\mu\text{m} = 12.2 \Omega/\mu\text{m}$

$RC \approx 100\text{ns}$

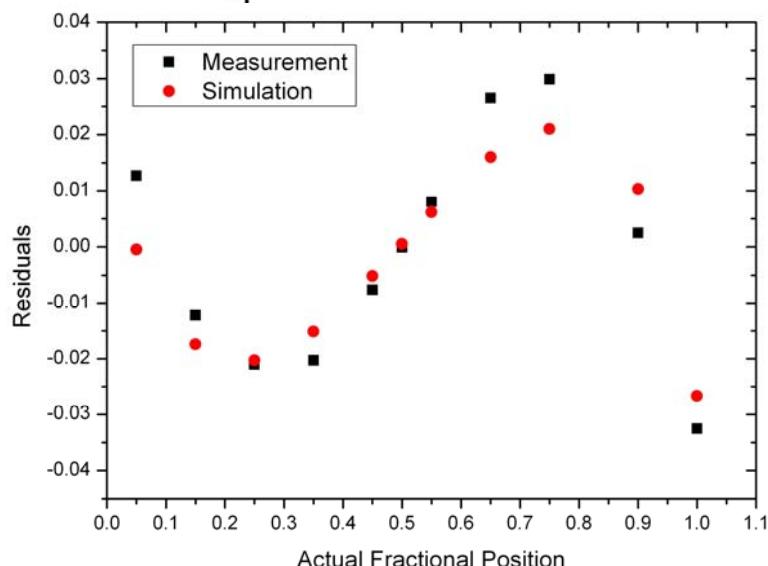
total charge collected  $\approx 35\text{fC}$

Calculated fractional position resolution  $\approx 2.2\%$

440  $\mu\text{m}$  over 20 mm



$$\frac{y}{L} = \frac{S_2}{S_1+S_2}$$



# Conclusion

**Novel 2D position-sensitive semiconductor detector concept based on the standard technology of AC coupled microstrip detectors.**

We have demonstrated the feasibility of resistive charge-division method in microstrip detectors to obtain longitudinal coordinate.

- ✓ **Different proof-of-concept prototypes** characterized with the use of a **NIR laser** and the **ALIBAVA DAQ system**.

Spatial resolution (in the best case) = 400  $\mu\text{m}$  over 20 mm for a total charge collected  $\approx 35\text{fC}$ .

- ✓ **Resistive electrodes** uncoupled from the diode structures of the detector.
- ✓ **A SPICE-like model** of the detectors and analog front-end electronics for future prototype optimization.

Applications in nuclear or particle physics tracking, laser-based position sensitive devices, heavy ion and other highly-ionizing particle detection, medical imaging, etc.

Currently the new prototypes are being tested at SPS pion beam at CERN.

Thank you for  
your attention!